

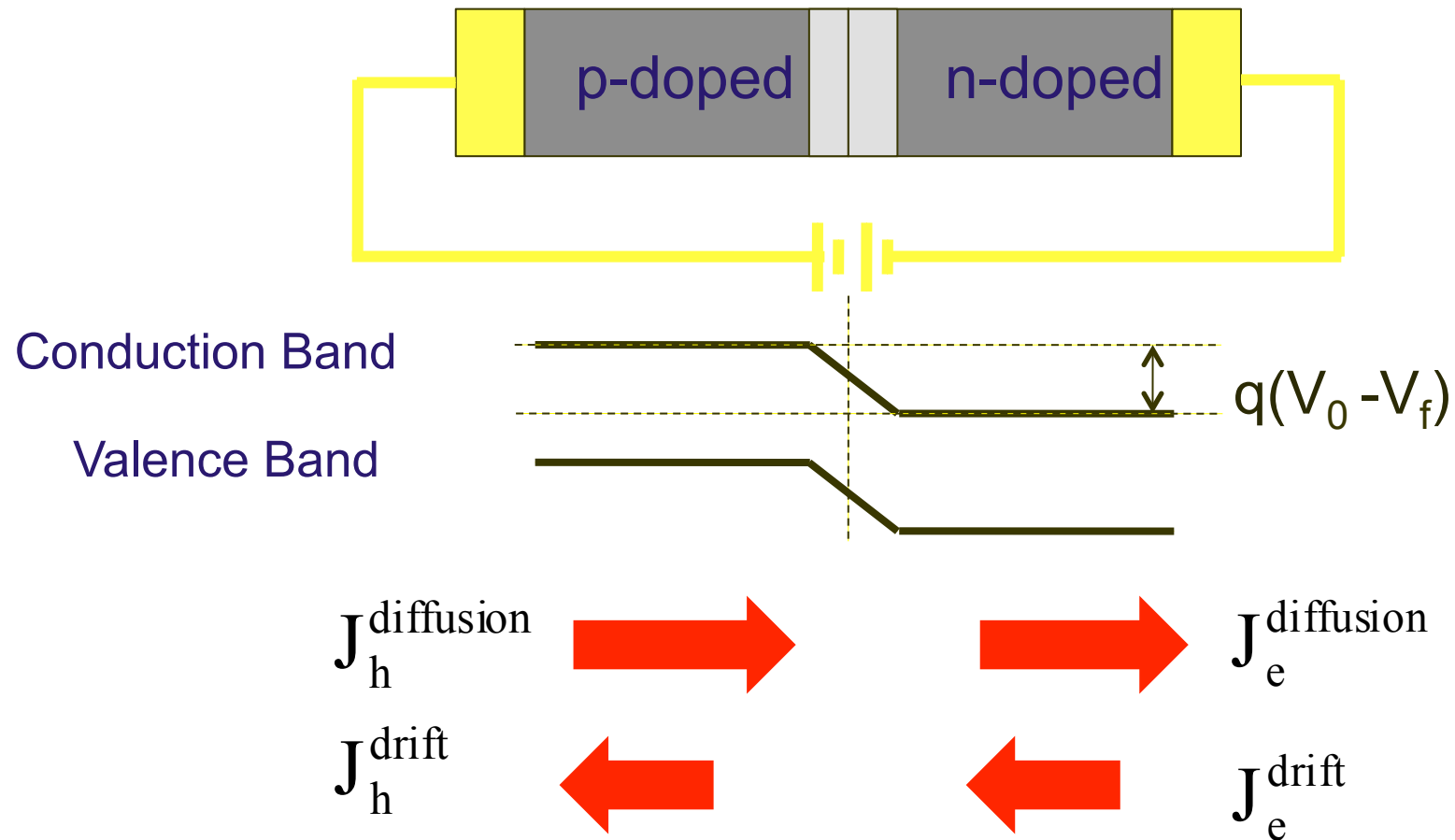


Lecture 12

- Forward Bias in p-n Junction – Qualitative
- Quantitative - derivation
- Diode equation



Forward Bias, V_f



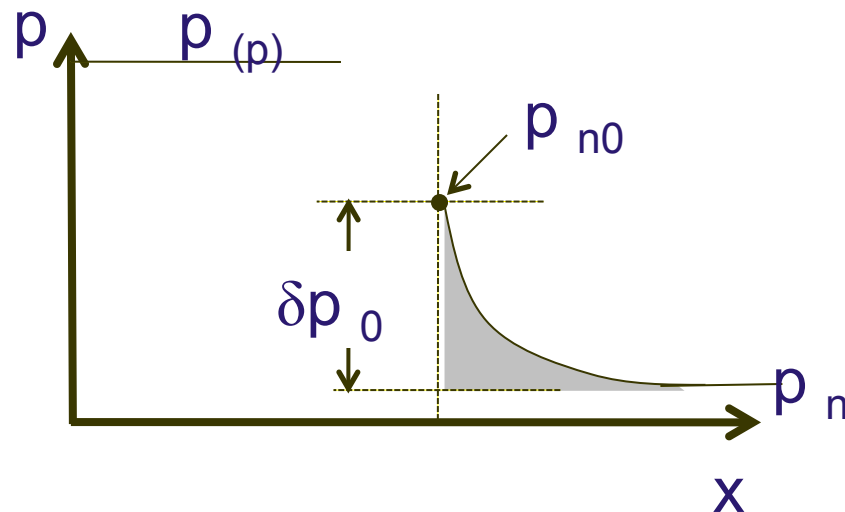
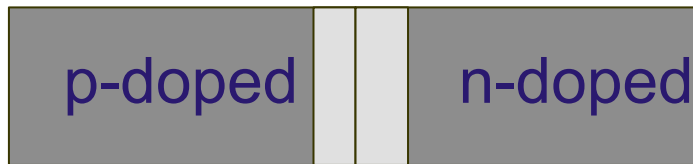
Forward Bias, V_f

- Applied voltage changes the potential barrier and thus E -field within junction region – since we have forward bias the potential barrier is reduced
- The electric field in the transition region reduces
- This reduces the transition region width (need fewer “exposed” ionized dopants to achieve this lower E -field)
- Diffusion Current – potential barrier smaller – so increased diffusion current
- Drift Current – essentially same as zero bias - very few minority carriers to contribute to drift–so very small

Our Job Today.....

- Calculate diffusion current of carriers (electrons into p-doped, holes into n-type) at fixed bias
- Recall discussion on steady state injection of one (minority) carrier
- We will calculate current as a function of applied voltage
- We will calculate charge injected per unit time by electrons and holes - work on one charge carrier type and modify equations for other carrier

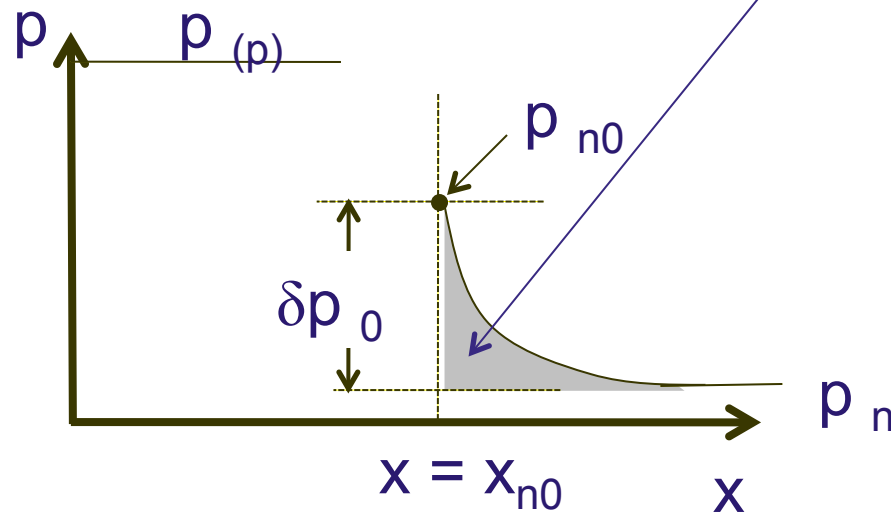
Consider Hole Diffusion



$$p_{n0} = p_n + \delta p_0$$

- Holes diffusing over barrier become excess minority carriers where they diffuse away from junction and recombine with majority electrons
- If bias is maintained we will achieve a continuous injection of minority holes (considered before) which will sustain an exponentially decreasing excess minority hole concentration
- Similar story for electron diffusion

Calculate $I(V_f)$



$$p_{n0} = p_n + \delta p_0$$

- Need to calculate area under this curve to get the charge Q_p
- The diffused (excess minority) hole concentration is a function of hole concentration in p-type
- We will use minority carrier lifetime as it will describe characteristic diffusion length
- Do this for holes and electrons and add together

Calculating δp_0

Recall Equation for built-in potential (NOTE: zero applied bias case)

$$V_0 = \frac{k_B T}{e} \ln \left(\frac{p_p}{p_n} \right) \quad \longrightarrow \quad p_n = p_p \exp \left[\frac{-e V_0}{k_B T} \right]$$

Modifying to include the applied forward bias, V_f , we get this in terms of p_{n0} , the minority carrier density at $x = x_{n0}$.

$$p_{n0} = p_p \exp \left[\frac{-e(V_0 - V_f)}{k_B T} \right]$$

Note $p_{n0} > p_n$ due to bias forward bias V_f

$$p_{n0} = p_n + \delta p_0 \quad \text{so} \quad \delta p_0 = p_{n0} - p_n$$

We have seen both of these previously, so:

$$\text{Using} \quad p_n = p_p \exp\left[\frac{-eV_0}{k_B T}\right]$$

$$\delta p_0 = p_p \exp\left[\frac{-e(V_0 - V_f)}{k_B T}\right] - p_p \exp\left[\frac{-eV_0}{k_B T}\right]$$

$$\delta p_0 = p_p \exp\left[\frac{eV_f}{k_B T}\right] \times p_p \exp\left[\frac{-eV_0}{k_B T}\right] - p_p \exp\left[\frac{-eV_0}{k_B T}\right]$$

Continued (2)

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Giving

$$\partial p_0 = p_n \left[\exp \left[\frac{eV_f}{k_B T} \right] - 1 \right]$$

And with a similar
treatment for electron
diffusion

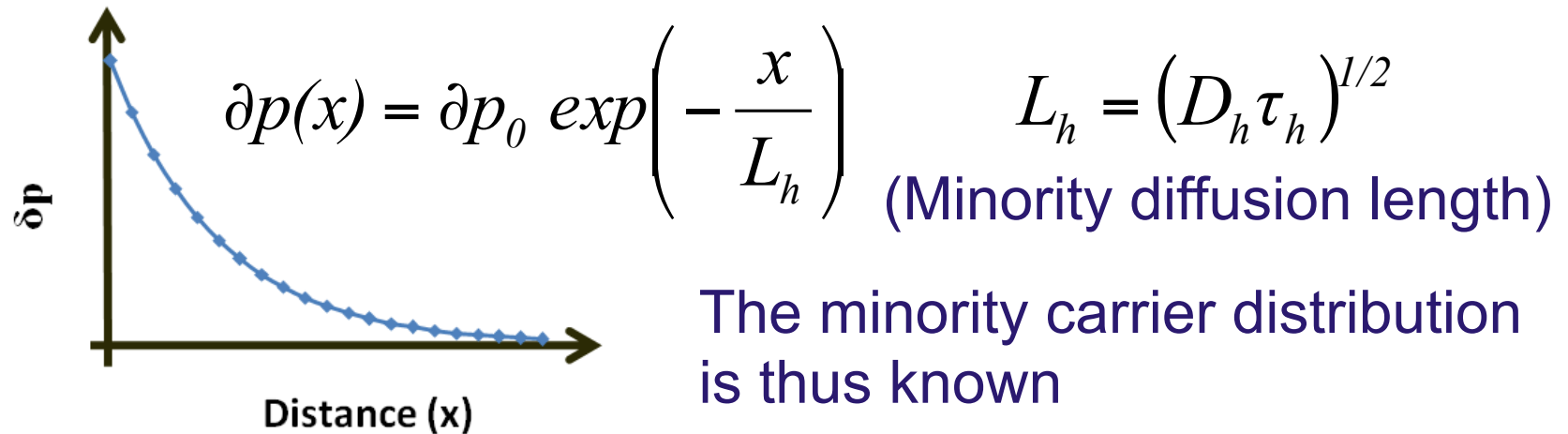
$$\partial n_0 = n_p \left[\exp \left[\frac{eV_f}{k_B T} \right] - 1 \right]$$

These show that the excess minority carrier concentration injected across the junction increases exponentially with forward bias V_f .

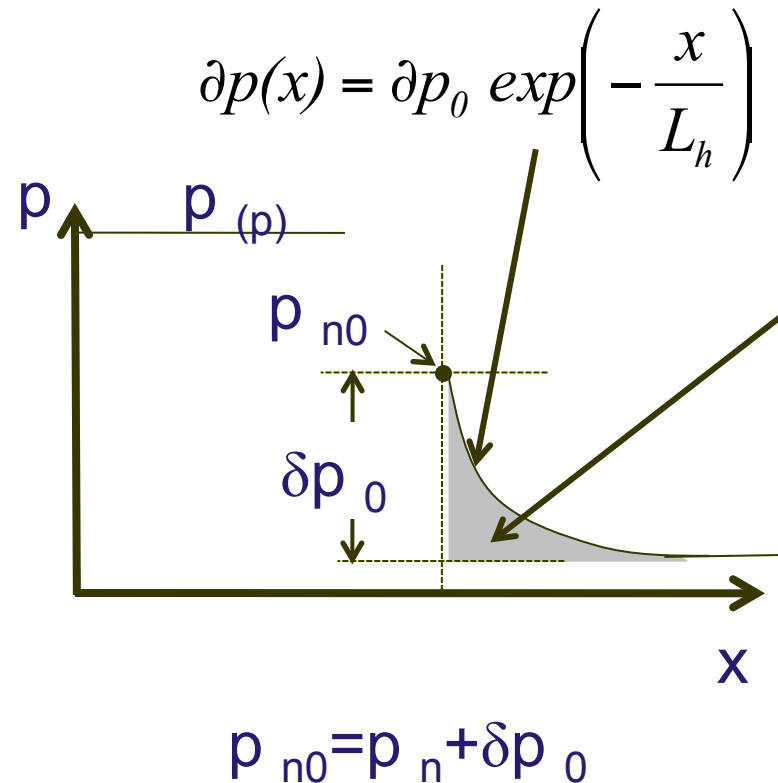
Continue with Deriving I (V_f)

We now need to include time and distances

Remembering minority carrier diffusion length – we can relate diffusion distance to minority carrier lifetime



From a previous lecture



Injected hole charge

$$Q_p = eA \int_0^{\infty} \delta p(x) dx$$

$$Q_p = eA \delta p_0 \int_0^{\infty} \exp\left(-\frac{x}{L_h}\right) dx$$

$$Q_p = eA \delta p_0 L_h$$

Similarly for electrons diffusing into the p-type material, charge injected, Q_e , is ;

$$Q_e = eA \delta n_0 L_e$$

Definite Integral Step

$$Q_p = eA\delta p_0 \int_0^\infty \exp\left(-\frac{x}{L_h}\right) dx$$

$$Q_p = qA\delta p_0 \left(\left[-L_h \exp\left(-\frac{x}{L_h}\right) \right]_{x=\infty} - \left[-L_h \exp\left(-\frac{x}{L_h}\right) \right]_{x=0} \right)$$

$$\lim_{x \rightarrow -\infty} \exp(x) = 0$$

$$\lim_{x \rightarrow 0} \exp(x) = 1$$

$$Q_p = eA\delta p_0 L_h$$

Putting It All Together

Diode current

$$I = I_e + I_h = \frac{Q_e}{\tau_e} + \frac{Q_h}{\tau_h} = \frac{eAL_e\delta n_0}{\tau_e} + \frac{eAL_h\delta p_0}{\tau_h}$$

Assumes excess charge
replenished every $\tau_{e,h}$ seconds

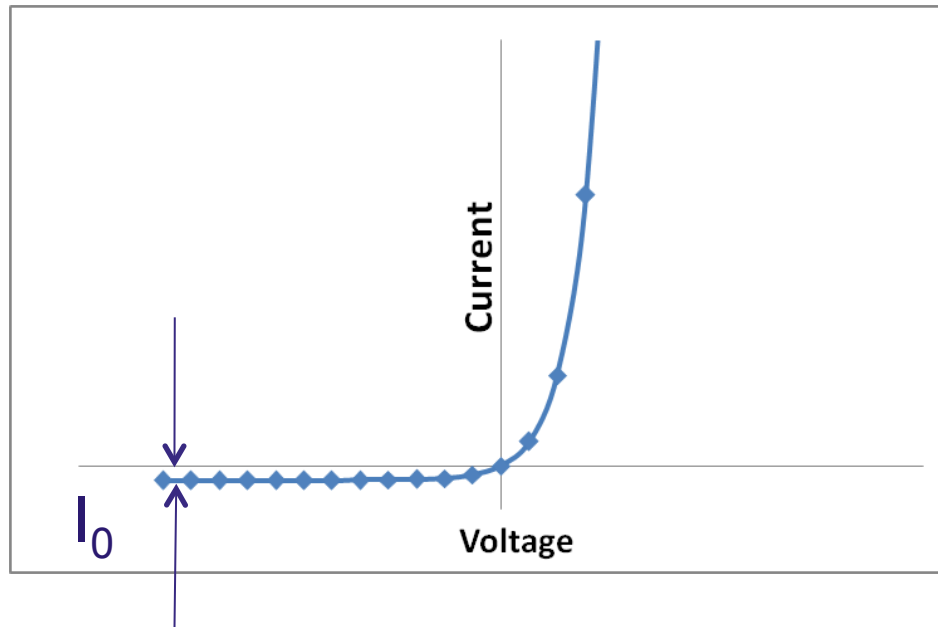
using $\delta p_0 = p_n \left[\exp\left[\frac{eV_f}{k_B T}\right] - 1 \right]$ and $\delta n_0 = n_p \left[\exp\left[\frac{eV_f}{k_B T}\right] - 1 \right]$

$$I = \left[\frac{eAL_e n_p}{\tau_e} + \frac{eAL_h p_n}{\tau_h} \right] \left[\exp\left(\frac{eV_f}{k_B T}\right) - 1 \right]$$



Can be + or - to reflect forward
and reverse bias

Diode Equation



$$I = I_0 \left[\exp\left(\frac{eV}{k_B T}\right) - 1 \right]$$

- Exponential increase in I with $V = V_f$
- For reverse bias $V \rightarrow -V \gg k_B T$ (large and negative)
 $I \rightarrow I_0$
- I_0 is the (reverse) saturation current

In terms of current density, J

$$J = J_0 \left[\exp\left(\frac{eV}{k_B T}\right) - 1 \right]$$



Saturation or Reverse Current

$$I_0 = I_{e0} + I_{h0} = eA \left[\frac{L_e n_p}{\tau_e} + \frac{L_h p_n}{\tau_h} \right]$$

Can be rewritten as

$$I_0 = eA n_i^2 \left[\frac{D_e}{L_e N_A} + \frac{D_h}{L_h N_D} \right]$$

using

$$L_h = (D_h \tau_h)^{1/2}$$
$$\left[\begin{array}{l} n_i^2 = p_p n_p = N_A n_p \\ n_i^2 = n_n p_n = N_D p_n \end{array} \right]$$

Summary

- The p-n junction under zero bias has a built-in potential preventing carrier diffusion
- Under forward bias the built-in potential is reduced, allowing carriers to diffuse more readily
- A continuous diffusion process across the junction is set up under a constant forward bias
- The recombination of diffusing excess minority carriers with majority carriers results in a current flow
- Forward current varies exponentially with applied bias - the diode equation
- Under reverse bias the (reverse or saturation) current is small and constant